



A35109-PCT-USA – 067515.0161

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Bong-Cheol Kim  
Serial No. : 10/089,479 Examiner : David Nhu  
Filed : March 28, 2003 Group Art Unit : 2818  
For : APPARATUS AND METHOD FOR FORMING SINGLE  
CRYSTALLINE NITRIDE SUBSTRATE USING HYDRIDE  
VAPOR PHASE EPITAXY AND LASER BEAM

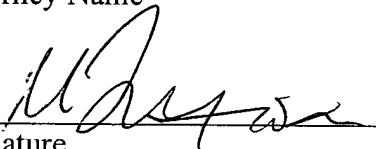
**REPLY TO OFFICE ACTION**

I hereby certify that this paper is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450.

September 26, 2003  
Date of Deposit

Manu J. Tejwani  
Attorney Name

37,952  
PTO Registration No

  
Signature

September 26, 2003  
Date of Signature

Commissioner of Patents  
P.O. Box 1450  
Alexandria VA D.C. 22313-1450

Sir:

In reply to the Office Action dated May 29, 2003, applicant amends claims as listed in the Claims section (page 2), and amends the specification as listed in the Amendments to the Specification section (page 5). A Replacement Drawing sheet is enclosed as described in the Amendments to Drawings section (page 8). Remarks are presented at page 9 of this paper.